

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No.: UCF-287

Application Serial No.: 09/881,620

Filed: 06/14/01

Examiner: Thomas Courtney D.

Group: 2882

For: EUV, XUV, AND X-RAY WAVELENGTH SOURCES CREATED FROM LASER PLASMA PRODUCED FROM LIQUID METAL SOLUTIONS

INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner of Patents
and Trademarks

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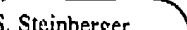
TECHNOLOGY CENTER 2800

Sir:

Pursuant to the requirements of 37 CFR 1.97 and 1.98, Applicant hereby requests that the references listed in the attached form PTO-1449 be considered and made of record in the above-identified application.

Favorable consideration of the application at an early date is respectfully solicited.

Respectfully submitted,


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SUPPLEMENTAL FORM PTO-1449

US DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICE

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LIST OF ART CITED BY APPLICANT

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OB RYMELL, L., et al., Droplet Target for Low-Debris-Laser-Plasma Soft X-ray Generation, No. ¼ pp. 105-110, Optics Communications, November (1993)